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Silicon N-Channel/P-Channel Complementary Power MOS FET Array



ADE-208-1216 (Z) 1st. Edition Mar. 2001

Application

High speed power switching

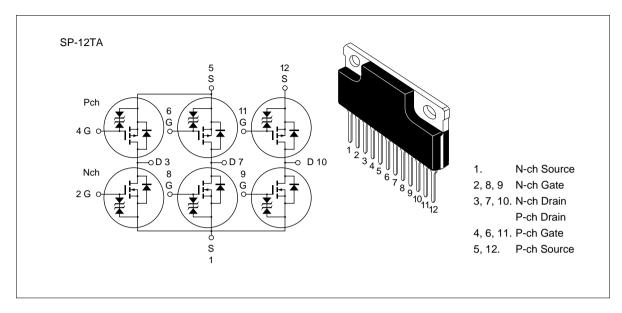
Features

Low on-resistance

N-channel: $R_{DS(on)} \le 0.17$, $V_{GS}=10$ V, $I_D=4$ A P-channel: $R_{DS(on)} \le 0.2$, $V_{GS}=-10$ V, $I_D=-4$ A

- Capable of 4 V gate drive
- Low drive current
- High speed switching
- High density mounting
- Suitable for H-bridged motor driver

Outline



Absolute Maximum Ratings (Ta = 25°C)

		Ratings		
Item	Symbol	Nch	Pch	Unit
Drain to source voltage	V _{DSS}	60	-60	V
Gate to source voltage	$V_{\rm GSS}$	±20	±20	V
Drain current	I_{D}	7	-7	A
Drain peak current	I _{D(pulse)} *1	28	-28	Α
Body to drain diode reverse drain current	I_{DR}	7	-7	A
Channel dissipation	Pch (Tc = 25°C)*2	42		W
Channel dissipation	Pch*2	4.8		W
Channel temperature	Tch	150		°C
Storage temperature	Tstg	-55 to	+150	°C

Notes: 1. PW \leq 10 μ s, duty cycle \leq 1%

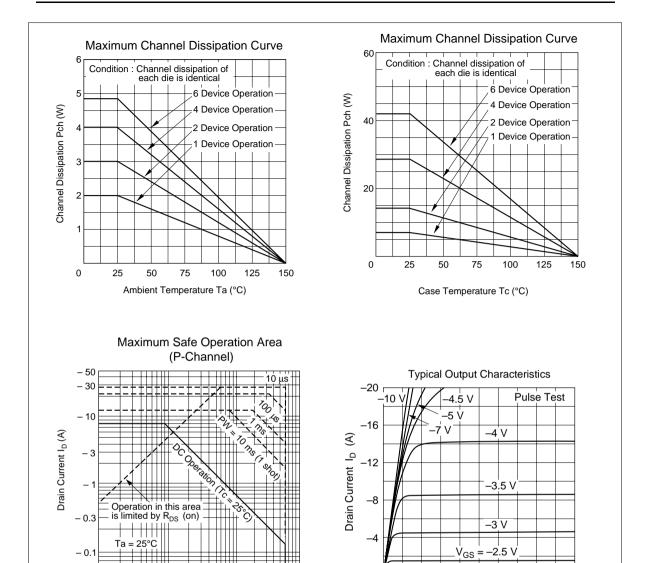
2. 6 devices operation

Electrical Characteristics (Ta = 25°C) (1 Unit)

		N channel		P channel					
Item	Symbol	Min	Тур	Max	Min	Тур	Max	Unit	Test conditions
Drain to source breakdown voltage	$V_{(BR)DSS}$	60		_	-60	_		V	$I_D = 10 \text{ mA}, V_{GS} = 0$
Gate to source breakdown voltage	$V_{(BR)GSS}$	±20		_	±20	_		V	$I_{G} = \pm 100 \ \mu A, \ V_{DS} = 0$
Gate to source leak current	I _{GSS}			±10	_	_	±10	μΑ	$V_{GS} = \pm 16 \text{ V}, V_{DS} = 0$
Zero gate voltage drain current	I _{DSS}	_		250	_	_	-250	μΑ	$V_{DS} = 50 \text{ V}, V_{GS} = 0$
Gate to source cutoff voltage	$V_{GS(off)}$	1.0		2.0	-1.0	_	-2.0	V	$I_D = 1 \text{ mA}, V_{DS} = 10 \text{ V}$
Static drain to source	R _{DS(on)}	_	0.13	0.17	_	0.15	0.2		$I_D = 4 \text{ A}, V_{GS} = 10 \text{ V}^{*1}$
on state resistance		_	0.19	0.24	_	0.20	0.27		$I_D = 4 \text{ A}, V_{GS} = 4 \text{ V}^{*1}$
Forward transfer admittance	y _{fs}	3.5	5.5	_	3.5	6.0	_	S	$I_D = 4 \text{ A}, V_{DS} = 10 \text{ V}^{*1}$
Input capacitance	Ciss	_	400	_	_	900	_	pF	$V_{DS} = 10 \text{ V}, V_{GS} = 0$
Output capacitance	Coss	_	220	_	_	460		pF	f = 1 MHz
Reverse transfer capacitance	Crss	_	60	_	_	130	_	pF	_
Turn-on delay time	t _{d(on)}	_	5	_	_	8		ns	$I_D = 4 A, V_{GS} = 10 V,$
Rise time	t _r	_	45	_	_	50	_	ns	$R_{L} = 7.5$
Turn-off delay time	t _{d(off)}	_	150	_	_	170		ns	_
Fall time	t _f	_	80	_	_	95	_	ns	=
Body to drain diode forward voltage	V_{DF}	_	1.1	_	_	-1.05	_	V	$I_F = 7 \text{ A}, V_{GS} = 0$
Body to drain diode reverse recovery time	t _{rr}	_	110	_	_	180	_	ns	$I_F = 7 \text{ A}, V_{GS} = 0,$ $dIF/dt = 50 \text{ A}/\mu\text{s}$
Note: 1. Pulse Test									

Note: 1. Pulse Test

Polarity of test conditions for P channel device is reversed.



0

-4

-8

-12

Drain to Source Voltage V_{DS} (V)

-16

-20

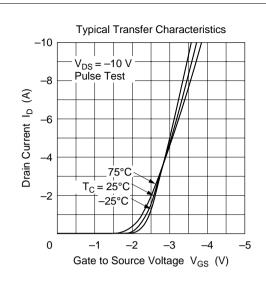
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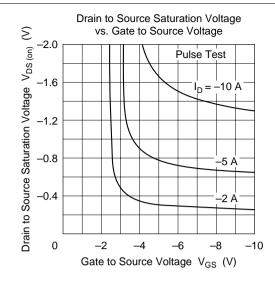
-0.3

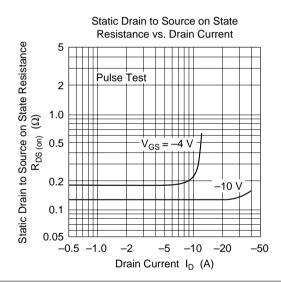
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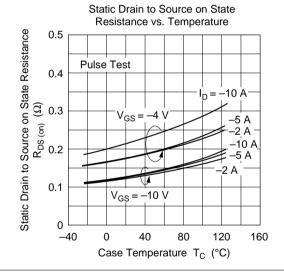
Drain to Source Voltage V_{DS} (V)

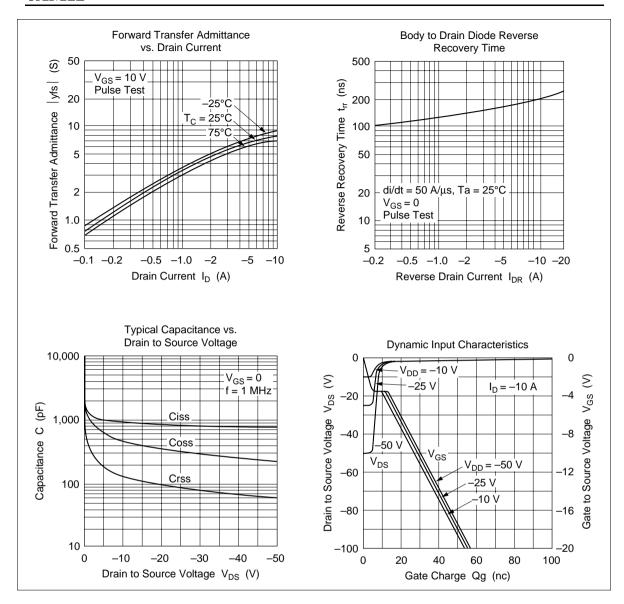
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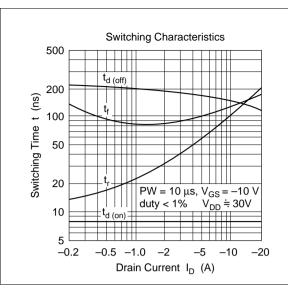


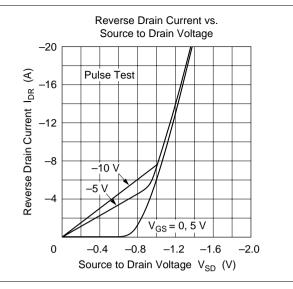


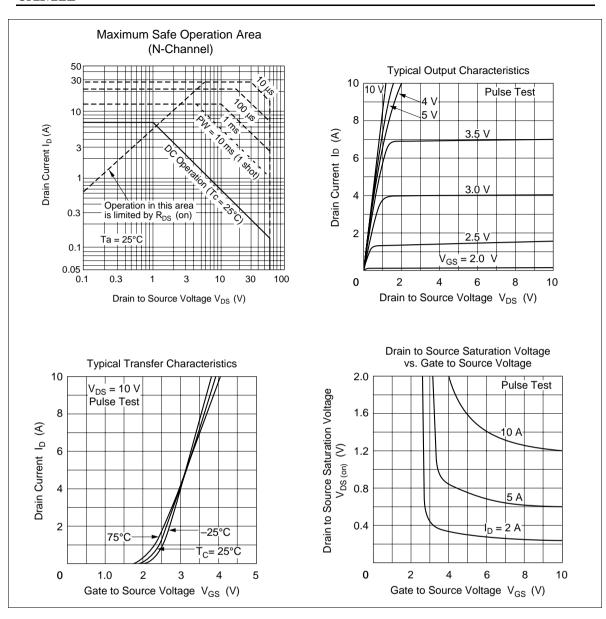


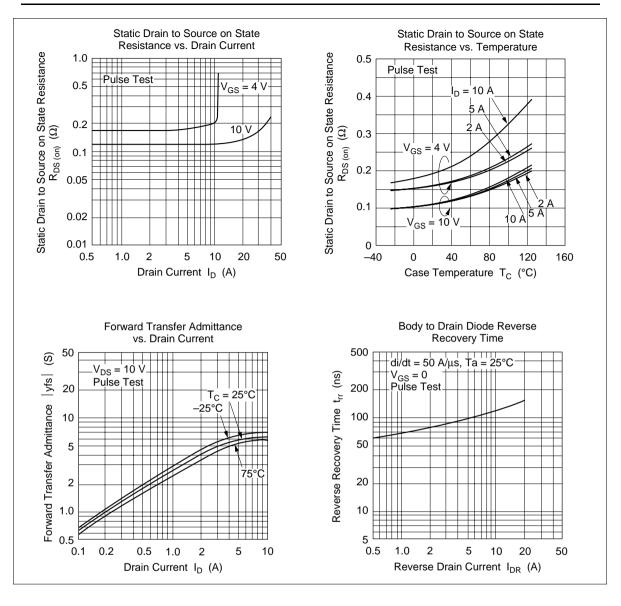


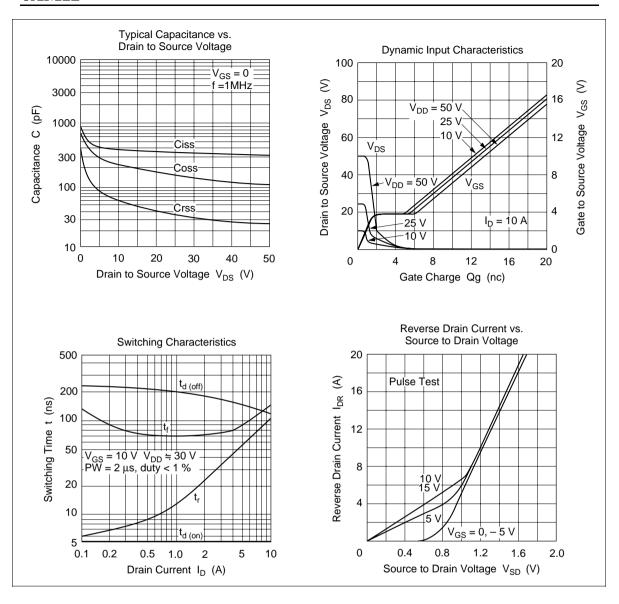




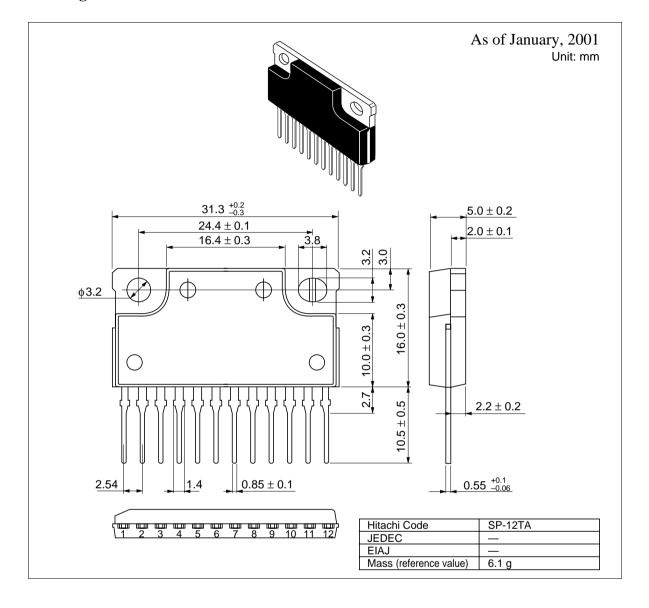








Package Dimensions



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